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LIST OF TRADEMARKS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT

ATTY. DOCKET NO.: P66218US0
SERIAL NO.: 09/720,259
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U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB- CLASS	FILING DATE (If Appropriate)
<u>Joe</u>	AA	<u>5,358,604</u>	<u>10/1994</u>	<u>LIN ET AL.</u>	<u>156</u>	<u>664</u>
<u>Joe</u>	AB	<u>5,512,131</u>	<u>4/1996</u>	<u>KUMAR ET AL.</u>	<u>156</u>	<u>655.1</u>
	AC					

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

Joe AR RD 419100 A (INT. BUSINESS MACHINES CORP) 20 FEBRUARY 1999
Contact Inking Stamps for Microcontact Printing Alkanethiois on Gold

Joe AS GUPTA, V.K. ET AL. Design of Surfaces For Patterned Alignment of Liquid Crystals on Planar And Curved Substrates. SCIENCE JUNE 1997, VOL. 276, 5318 PP. 1533-1536, ISSN 0036-8075

Joe AT AKSAY, I.A. ET AL. Biomimetic Pathways For Assembling Inorganic Thin Films, SCIENCE, AUGUST 1996, VOL. 273 5277 PP. 892-897, ISSN 0036-8075

Joe AU ZHAO, X-M "Microfabrication using soft lithography (waveguides, self assembled monolayers, surface defects, shrinkable polystyrene, etching)", 1998, Vol. 59/10-B of dissertation abstracts international side 5538. 234 sider. (sammendrag) Dissertation Abstracts Online. Bell & Howell Information and Learning, 300 North Zeeb Road, Ann Arbor, MI...

Joe AV XIA, Y. "Soft Lithography: Micro- and nanofabrication based on micro contact printing and replica molding". 1996, Vol 57/10-B of dissertation abstracts international side 5538. 307 sider. Dissertation Abstracts Online. Bell & Howell Information and Learning...

EXAMINER

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* EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant(s).